APPLICATION NOTE
LD15-04

Measurement of silane purity in electronic gases industry using PlasmaDetek-E and MultiDetek2

▲ MultiDetek2 ▲ PlasmaDetek-E

Silane (SiH_4), more properly known as monosilane and alternately called silicon tetrahydride or silicane, is a highly flammable and hazardous chemical compound containing silicon (87.45%) and hydrogen (12.55%). With silicon comprising 87.45% of its content by weight, pure silane is a primary source of high-purity silicon for use in industry. It is a critical gas in the manufacture of semiconductor devices, display panels and other electronic devices. The analysis of ultra low part per billion of permanent gases in silane is required for measuring the silane purity. The use of the LDetek compact & industrial MultiDetek2 GC combined with the PlasmaDetek-E is the perfect fit for this domain of application.

LDETEK SOLUTION:

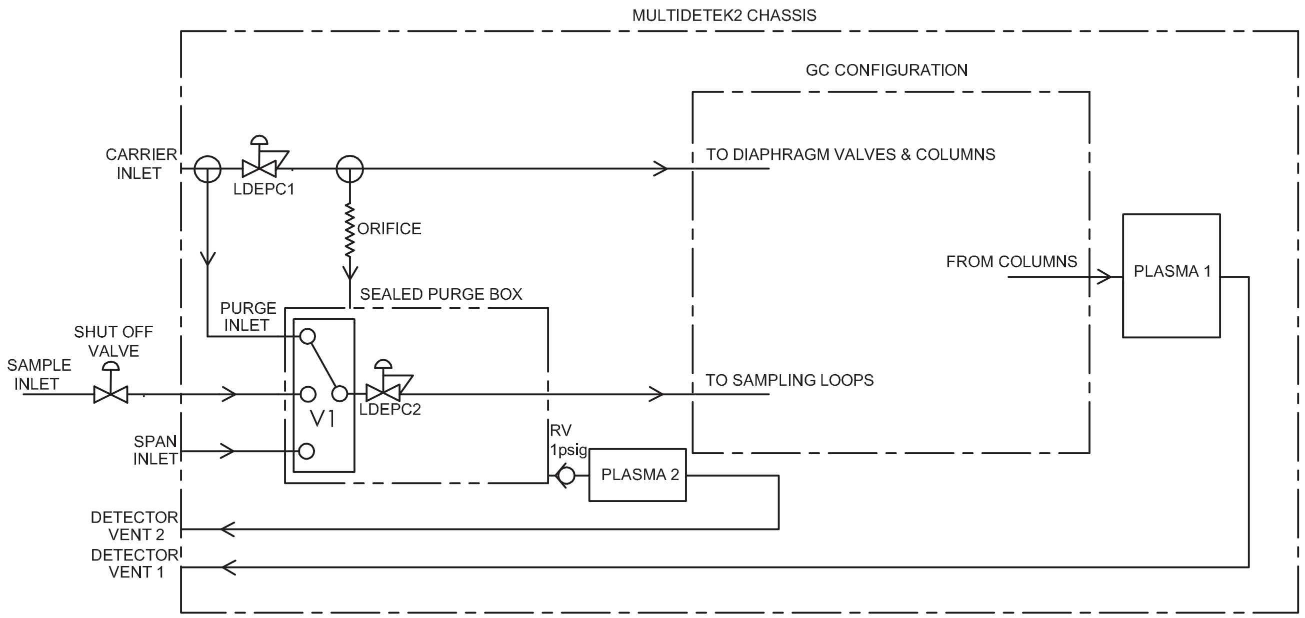
Handling highly flammable gases like silane requires a high level of safety and this is what LDetek offers with its built-in sample purging and monitoring system inside the MultiDetek2 compact GC. This system consists of 4 steps of safety:

Step 1: The sample gas flow path external to the purge box is fully welded offering no possibility of leakage.

Step 2: A selection valve (V1) is mounted before the diaphragm valves used for filling the sampling loops in the system. That selection valve (V1) is configured to allow silane to go to the sampling loops only for a predetermined period of time, just before the start of each analysis. The short period of time is configured in the factory and depends on the system configuration. The rest of the time, the selection valve (V1) is switched to a purge gas, which is normally the same gas type as the carrier gas of the system for purging the sampling loops. In the eventuality of leakage on the sampling loops or on the injection diaphragm valves, the reduced period of time introducing silane in the injection valves combined with the low pressure operation and small volume will avoid any potential hazardous situation.

Step 3: A sealed purge box containing the sample flow electronic pressure controller (LDEPC2) and the diaphragm selection valve (V1) is mounted in the MultiDetek2 chassis. That box is normally purged with the same gas type as the carrier gas used for the system. That environment requires low purge flow rate of about 10-30 sccm through a fixed orifice depending on the system configuration. The box is fully ambient air free and the system is ready to use after a short period of about 20-30 minutes depending on the system configuration. This waiting period is only required for initial start-up since once the MultiDetek2 has carrier flow going in it, the box is continuously on purge. Having a box fully purged with UHP carrier gas eliminates the ignition risk in potential presence of silane. A 1psig relief valve (RV) is mounted on the box to build up a minimum sealing pressure and to maintain a constant purge with the carrier gas.

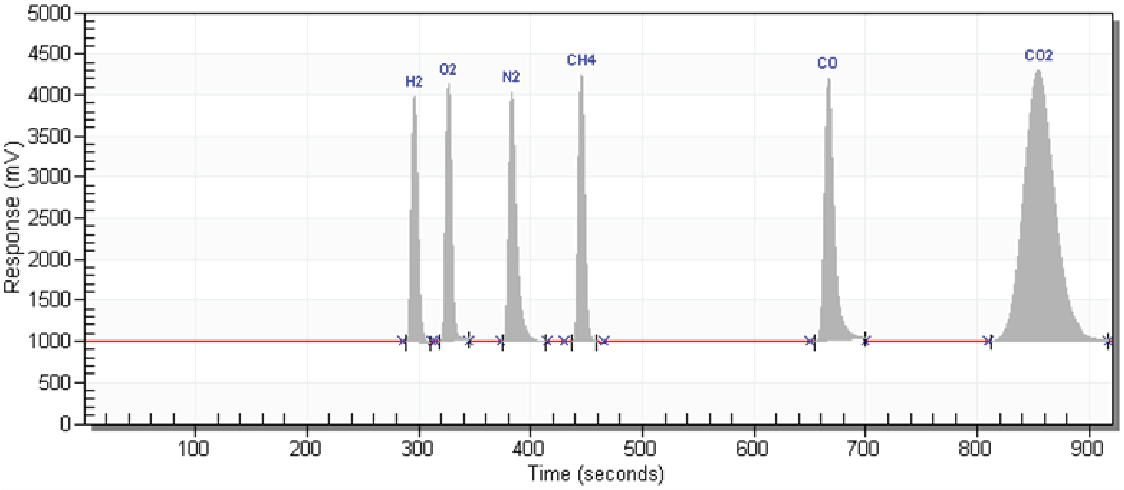
Step 4: The sealed purge box is continuously monitored using a micro PED (PLASMA2) to selectively measure trace N2 to ensure there is no air contamination in the sealed box to avoid the ignition in the potential presence of silane. If trace of air is measured in the purge box by the micro PED (PLASMA2), then an alarm is activated to shut off the flow of silane gas inside the MultiDetek2. The shut-off valve must be mounted external to the MultiDetek2 chassis. The feedback signal controlling the shut off valve comes from the MultiDetek2. It is required to maintain the sample gas pressure coming to the shut-off valve below 10psig to minimize the risk of ignition.



The flow type selected by the selection valve (V1) is controlled with the electronic flow controller (LDEPC2) to ensure a stable and constant flow rate whichever the selected gas type.

The GC configuration for this application is configured with Stainless Steel purge diaphragm valves and MXT column types. At the end of the GC configuration, a PlasmaDetek-E detector is configured to selectively measure the impurities requested. Multiple channels can be configured depending on the application. For this application note, the analysis of H_2-O_2-N_2-CH_4-CO is measured through channel #1 and the CO_2 through channel#2. Both channels are combined together and go in the PlasmaDetek2 detector. The highly sensitive PlasmaDetek-E allows good detection limit, what is required for silane purity.

RESULTS:



Chromatogram :
Trace impurities in silane

Chart : LDL calculation

COMPONENT	CONCENTRATION	PEAK HEIGHT	NOISE	LDL (3X NOISE)
H_2	808ppb	2995mV	3mV	2.5ppb
O_2	810ppb	3220mV	3mV	2ppb
N_2	810ppb	3095mV	2mV	1.5ppb
CH_4	810ppb	3335mV	3mV	2ppb
CO	820ppb	3297mV	4mV	3ppb
CO_2	820ppb	3380mV	3mV	2ppb

Note: other LDL could be obtained with different injection volume and chromatographic condition.

CONCLUSION:

The PlasmaDetek-E and the MultiDetek2 combined with the highly safe continuous monitoring sampling system allow the measurement of silane purity with reduced risk. The N2 monitoring of the purge box is essential to ensure there is no ignition risk inside the MultiDetek2.

The measurement of trace of impurities can be performed with a relatively short analysis time, and can offer very low limit of detection what is required for silane purity.

LDetek

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